Search Notes

Application/Control No.	Applicant(s)/Patent under Reexamination
10/712,333	KOIKE ET AL.
Examiner	Art Unit
W. David Coleman	2823

SEARCHED				
Class	Subclass	Date	Examiner	
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INTERFERENCE SEARCHED				
Class	Subclass	Date	Examiner	
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SEARCH NOTES (INCLUDING SEARCH STRATEGY)			
	DATE	EXMR	
EAST 2.0.1 Applicant claims a reticle mask having various types fo alignment marks and a support structure for the mask.	2/15/2005	WDC	
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